

Morphology-dependent enhancement of the electrochemical performance of CNF-guided tunable VS₄ heterostructures for symmetric supercapacitors

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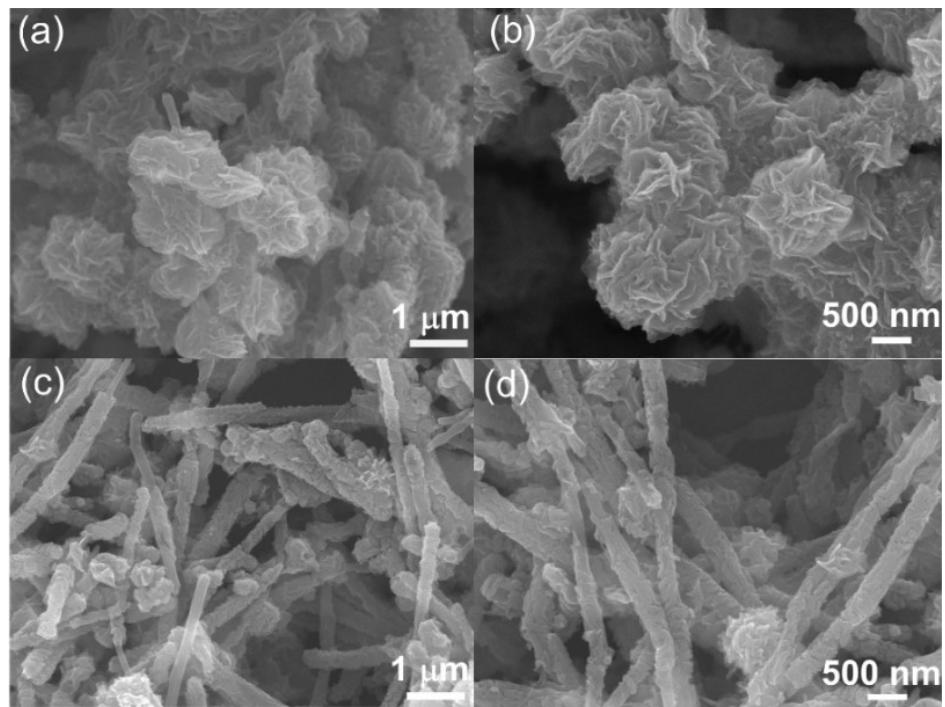


Figure S1. Scanning electron microscopy (SEM) images of (a-b) $\text{VS}_4@\text{CNF}_x$, and (c-d) $\text{VS}_4@\text{CNF}_{3x}$ at different magnifications.

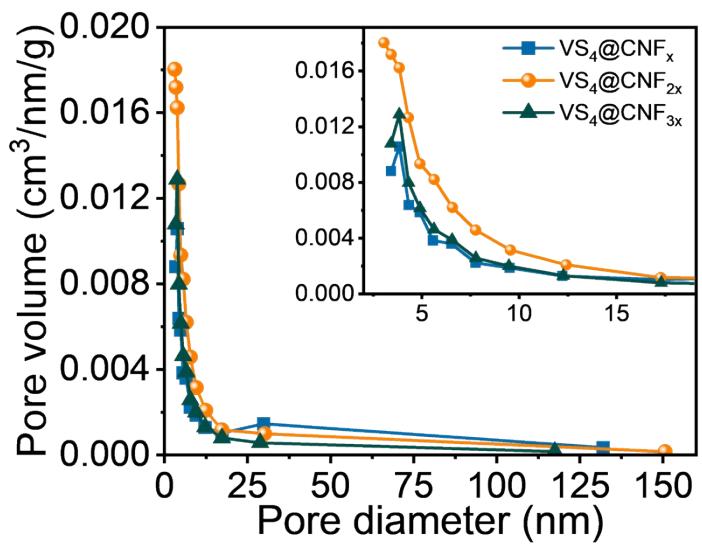


Figure S2. BJH pore size distribution curve of $\text{VS}_4@\text{CNF}_{x-3x}$ composite.

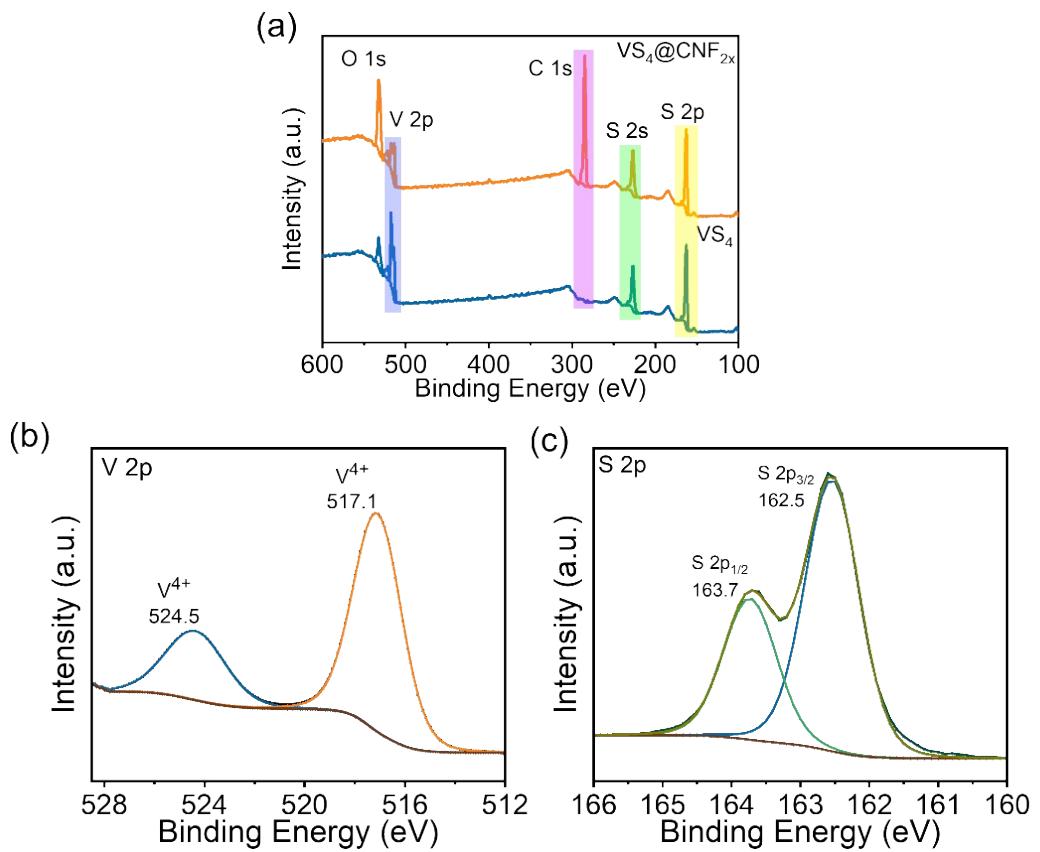


Figure S3. XPS (a) stacked spectra of VS₄ and VS₄@CNF_{2x}, and deconvoluted XPS peaks for VS₄ (b) V and (c) S, respectively.

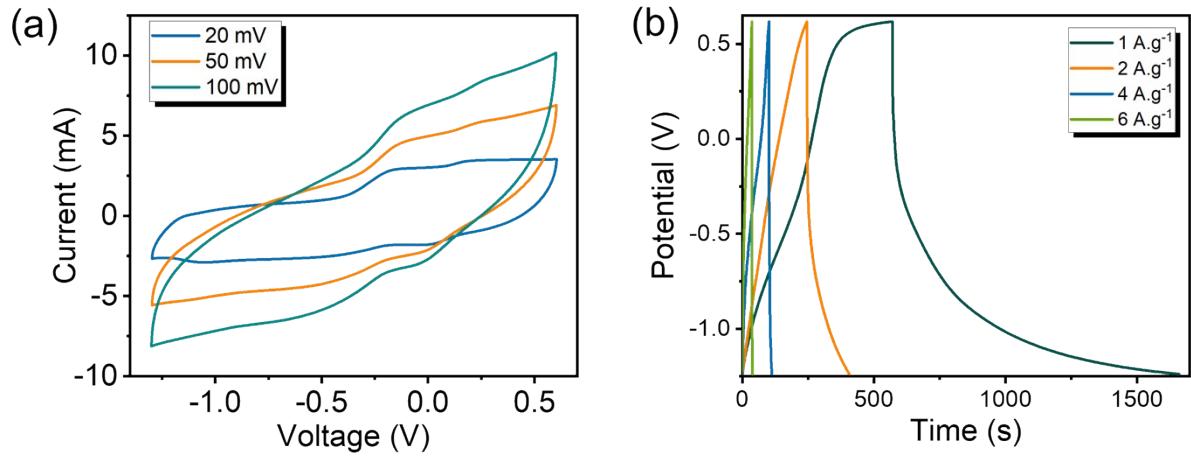


Figure S4. (a) CV curve of VS₄ at different scan rates, and (b) GCD curve of VS₄ at different current density.

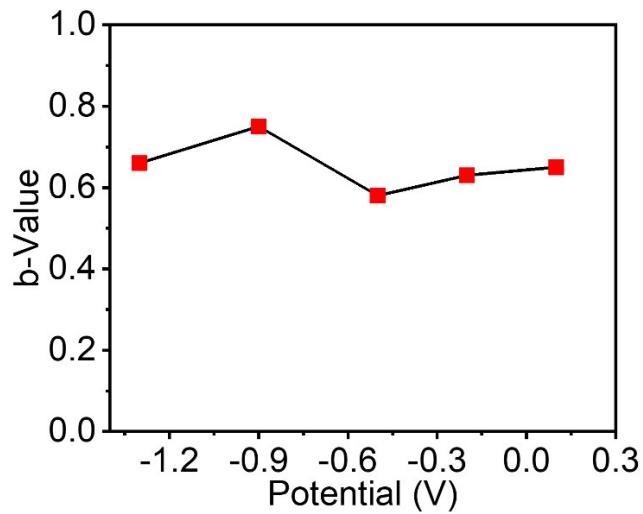


Figure S5. Calculating the slope b obtained by plotting $\log(i)$ vs $\log(v)$.

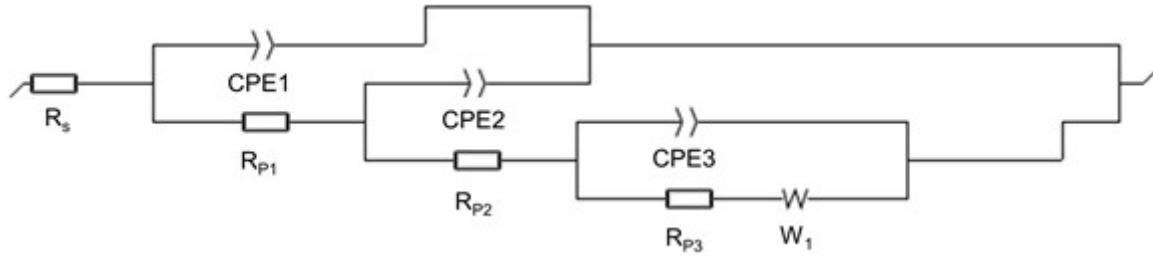


Figure S6. The equivalent electrical circuit fit for VS₄@CNF_x, VS₄@CNF_{2x}, and VS₄@CNF_{3x}.

Table S1. EIS fitted parameters of VS₄@CNF_x, VS₄@CNF_{2x}, and VS₄@CNF_{3x} based SC.

Parameter	R _s (ohm)	R _{P1} (ohm)	CPE1 (S×s ^a) ×10 ⁻³	N1	R _{P2} (ohm)	CPE2 (S×s ^a) ×10 ⁻³	N2	R _{P3} (ohm) ×10 ⁻³	CPE3 (S×s ^a) ×10 ⁻³	N3	W ₁
VS ₄ @CNF _x	5.359	0.998	0.782	0.701	24.06	185.7	0.637	1.496	207	1	0.095
VS ₄ @CNF _{2x}	5.100	0.485	0.336	0.835	13.28	103.1	0.741	1.076	304	0.851	0.019
VS ₄ @CNF _{3x}	5.274	1.295	0.391	0.508	24.81	204	0.705	4.32	238	0.932	0.029

Table S2. Comparison of VS₄@CNF_{2x} electrode performance with the other reported materials.

Electrode Material	Electrolyte	Specific Capacitance	Retention (after Cycles)	Energy Density (W h kg ⁻¹)	Power Density (W kg ⁻¹)
VS ₄ nanorods ¹	1 M LiNO ₃	617 F/g @ 0.4 A/g	87.5% (1500)	55	-
Hydrangea-like VS ₄ microsphere ²	1 M Na ₂ SO ₃	533 F/g @ 0.1 A/g	80% (500)	60	-
Anemone-like VS ₄ microsphere ³	1 M LiNO ₃	617 F/g @ 0.4 A/g	87.5% (1500)	113.6	720
Petal shape VS ₄ /CNT ⁴	1 M LiClO ₄	330 F/g @ 1 A/g	63% (5000)	51.2	30.95
VS ₄ /CNT/rGO ⁵	1 M LiClO ₄ /PC	490.7 F/g @ 1 A/g	50% (2000)	72.07	14.69
VS ₄ /CNTs/RGO ⁶	0.5 M K ₂ SO ₄	558.7 F/g @ 1 A/g	90% (1000)	174.6	13.85
NiS ₂ @NiV ₂ S ₄ ⁷	6 M KOH	520 C/g at 1 A/g	90% (10000)	19.4	140
VS ₄ /rGO ⁸	1 M Na ₂ SO ₄	877 F/g @ 0.5 A/g	90% (1000)	117	20
rGO-VS ₂ -WS ₂ ⁹	3 M KOH	220 F/g @ 1 A/g	-	30.55	355
VS₄@CNF_{2x} This work	1 M KOH	840 F/g @ 1 A/g	86% (5000)	91	239

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